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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO | . CONFIRMATION NO. | |
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| 10/815,429 | 03/31/2004 | Richard Hsiao | HIT1P041B/SJ0920010089 | HIT1P041B/SJ0920010089US3 7633 | |
| 50535 ZILKA-KOTAF | 7590 04/13/200 B. PC | EXAMINER | | | |
| P.O. BOX 7211 | 20 | TUGBANG, ANTHONY D | | | |
| SAN JOSE, CA 95172-1120 | | | ART UNIT | PAPER NUMBER | |
| | | | 3729 | 3729 | |
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| SHORTENED STATUTORY | Y PERIOD OF RESPONSE | MAIL DATE | . DELIV | . DELIVERY MODE | |
| 3 MONTHS | | 04/13/2007 | | DADED | |

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

| | | Application No. | Applicant(a) | | | |
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| | • • | Application No. | Applicant(s) | | | |
| | | 10/815,429 | HSIAO ET AL. | | | |
| ` | Office Action Summary | Examiner | Art Unit | | | |
| | | A. Dexter Tugbang | 3729 | | | |
| Period fo | The MAILING DATE of this communication app or Reply | ears on the cover sheet with the c | orrespondence address | | | |
| A SH WHIC - Exter after - If NC - Failu Any | ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DA nsions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Depriod for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b). | ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE! | N. nely filed the mailing date of this communication. D (35 U.S.C. § 133). | | | |
| Status | | | | | | |
| 2a)⊠ | Responsive to communication(s) filed on 16 Ja This action is FINAL . 2b) This Since this application is in condition for allower closed in accordance with the practice under E | action is non-final. | | | | |
| Dispositi | on of Claims | | | | | |
| 5)⊠ 6)⊠ 7)⊠ 8)□ Applicati 9)□ 10)□ | Claim(s) 1-24 is/are pending in the application. 4a) Of the above claim(s) 20-24 is/are withdraw Claim(s) 1,3-13 and 17 is/are allowed. Claim(s) 2,18 and 19 is/are rejected. Claim(s) 14-16 is/are objected to. Claim(s) are subject to restriction and/or on Papers The specification is objected to by the Examined The drawing(s) filed on is/are: a) access Applicant may not request that any objection to the or Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examined Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examined Replacement of the oath or declaration is objected to by the Examined Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examined Replacement of the oath or declaration is objected to by the Examined Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examined Replacement of the oath or declaration is objected to by the Examined Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examined Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examined Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examined Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examined Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examined Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examined Replacement drawing sheet(s) including the correction of the oath of the oath or declaration is objected to be objected to | n from consideration. relection requirement. r. epted or b) objected to by the Edrawing(s) be held in abeyance. See ion is required if the drawing(s) is obj | e 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d). | | | |
| Priority u | inder 35 U.S.C. § 119 | ÷ | | | | |
| 12)[a)[| Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priorical prioric | s have been received. s have been received in Application ity documents have been receive (PCT Rule 17.2(a)). | on No d in this National Stage | | | |
| 2) 🔲 Notice 3) 🔲 Inform | e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO/SB/08) | 4) Interview Summary (Paper No(s)/Mail Da 5) Notice of Informal Pa | te | | | |
| Paper | Paper No(s)/Mail Date 6) Other: | | | | | |

DETAILED ACTION

Response to Amendment

- 1. The applicant(s) amendment filed on January 16, 2007 has been fully considered and made of record.
- 2. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

Election/Restrictions

3. Claims 1, 3 through 13 and 17 are allowable for the reasons noted below. The election of species requirement between Species A through D, as set forth in the Office action mailed on August 15, 2006 (note paragraph 4), has been reconsidered in view of the allowability of generic claim 1 in the elected invention pursuant to MPEP § 821.04(a). The restriction requirement is hereby withdrawn as to any claim that requires all the limitations of an allowable claim.

Claims 7 through 9, directed to Species B through D are no longer withdrawn from consideration because the claim(s) requires all the limitations of an allowable claim (e.g. generic Claim 1).

However, Claims 20 through 24, directed to the invention of Group II continue to stand as being withdrawn from consideration because the invention of Group II is directed to product claims, which do not require all the limitations of an allowable claim.

In view of the above noted withdrawal of the restriction requirement, applicant is advised that if any claim presented in a continuation or divisional application is anticipated by, or includes all the limitations of, a claim that is allowable in the present application, such claim may

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be subject to provisional statutory and/or nonstatutory double patenting rejections over the claims of the instant application.

Once a restriction requirement is withdrawn, the provisions of 35 U.S.C. 121 are no longer applicable. See *In re Ziegler*, 443 F.2d 1211, 1215, 170 USPQ 129, 131-32 (CCPA 1971). See also MPEP § 804.01.

Claim Rejections - 35 USC § 103

4. Claims 2, 18 and 19 are rejected under 35 U.S.C. 103(a) as being unpatentable over the AAPA in view of Wei et al.

The AAPA (specification, pages 1-3 and Prior Art Figures 1 and 2) discloses a process of making a pole or coil structure comprising: depositing a conductive layer (e.g. 106) of Cu; depositing a photoresist layer (e.g. 108) on the conductive layer; forming a channel in the photoresist layer; and filling the channel with a conductive material (e.g. 110, 111) to define a coil structure.

The AAPA does not teach depositing a silicon dielectric layer on the photoresist layer; masking the silicon dielectric layer; and etching at least one channel in both the photoresist layer and the silicon dielectric layer.

Wei discloses a patterning process that includes depositing a silicon dielectric layer (e.g. 64); masking the silicon dielectric layer (with mask 65); and etching at least one channel in the photoresist layer and the silicon dielectric layer (see sequence of Figs. 7 to 8). The patterning process of Wei is to provide the channel to fill the channel with a conductive material (e.g. 423).

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It is noted that both the AAPA and Wei teach art recognized equivalent processes of forming at least one channel to pattern and fill it with a conductive material.

Regarding Claim(s) 19, Wei further teaches that the conductive material can be one of a magnetic material, or a magnetic pole P2 tip structure (col. 4, lines 7-19).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to have modified the method of the AAPA by including the patterning process of Wei, to perform an art recognized equivalent process of filling a channel with conductive material to provide a patterned conductive material.

Response to Arguments

5. The applicant(s) arguments, see pages 12 to 17 of the response filed on January 16, 2007, with respect to the features of the "aspect ratio" and the "grain size", have been fully considered and are persuasive. Since the features of the aspect ratio size and the grain size are specifically recited in each of Claims 1, 14 and 15, the prior rejections of Claims 1, 14 and 15, each have been withdrawn.

The examiner notes that aspect ratio is well known in the art as to the reference of the ratio of height to width. In this case, the applicant(s) are correct to note that the aspect ratio (height/width) of the at least one channel being about 7 is not taught by the prior art.

Additionally regarding the "grain size", the examiner's position is that the conductive material (e.g. Cu) deposited into the one channel inherently has a grain size. The textbook cited to Smith show that metals inherently have a grain (crystal structure) size. However, the AAPA

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and the prior art <u>do not state</u> what the grain (e.g. crystal) size **is** relative to *half* of a smallest dimension of the at least one channel.

6. The applicant(s) arguments with respect to Claims 2, 18 and 19 and the combination of the AAPA and Wei et al, have not been found to be persuasive the rejections are maintained for the following reasons.

In response to the applicant(s) argument that Wei utilizes additional processing steps, thus changing the operation of the AAPA, the test for obviousness is not whether the features of a secondary reference may be bodily incorporated into the structure of the primary reference; nor is it that the claimed invention must be expressly suggested in any one or all of the references. Rather, the test is what the combined teachings of the references would have suggested to those of ordinary skill in the art. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981).

Both the AAPA and Wei et al are concerned with solving problems associated with forming at least one channel to pattern and fill it with a conductive material. So the examiner's position is that the modification of the AAPA in view of Wei would be proper in order to solve this very same problem and would therefore be obvious.

In response to applicant's argument that the examiner's conclusion of obviousness is based upon improper hindsight reasoning, it must be recognized that any judgment on obviousness is in a sense necessarily a reconstruction based upon hindsight reasoning. But so long as it takes into account only knowledge which was within the level of ordinary skill at the time the claimed invention was made, and does not include knowledge gleaned only from the applicant's disclosure, such a reconstruction is proper. See *In re McLaughlin*, 443 F.2d 1392, 170 USPQ 209 (CCPA 1971).

Allowable Subject Matter

- 7. Claims 1, 3 through 13 and 17 are allowed.
- 8. Claims 14 through 16 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Conclusion

9. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to A. Dexter Tugbang whose telephone number is 571-272-4570. The examiner can normally be reached on Monday - Friday 7:30 am - 4:00 pm.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Peter Vo can be reached on 571-272-4690. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

A. Dexter Tugbang Primary Examiner Art Unit 3729

April 2, 2007